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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/645,591	08/22/2003	. Takatoshi Nishizawa	240897US0CONT 9480	
22850	7590 09/27/2005	EXAMINER		
•	VAK, MCCLELLAI	PATTERSON, MARC A		
1940 DUKE S ALEXANDRI	A, VA 22314		ART UNIT	PAPER NUMBER
	•		1772	

DATE MAILED: 09/27/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

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Office Action Summary		Application (NO.	Applicant(s)			
		10/645,591		NISHIZAWA ET A	L.		
		Examiner		Art Unit			
		Marc A. Patte	erson	1772			
Period fo	The MAILING DATE of this communication a pr Reply	appears on the co	over sheet with the c	orrespondence ad	dress		
WHI(- Exte after - If NO - Failu Any	IORTENED STATUTORY PERIOD FOR REPORTED STATUTORY PERIOD FOR REPORTS IS LONGER, FROM THE MAILING ensions of time may be available under the provisions of 37 CFR SIX (6) MONTHS from the mailing date of this communication. O period for reply is specified above, the maximum statutory period reply within the set or extended period for reply will, by state reply received by the Office later than three months after the mailed patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS 1.136(a). In no event, I iod will apply and will ex itute, cause the applicati	COMMUNICATION however, may a reply be timpire SIX (6) MONTHS from ion to become ABANDONE	N. nely filed the mailing date of this co D (35 U.S.C. § 133).			
Status							
1)□ 2a)□	Responsive to communication(s) filed on This action is FINAL . 2b) \(\sum T)	his action is non-	-final				
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
,—	closed in accordance with the practice unde						
Disposit	ion of Claims						
5)□ 6)⊠ 7)□ 8)□ Applicat 9)□ 10)□	Claim(s) 1-12 is/are pending in the application 4a) Of the above claim(s) is/are withdout claim(s) is/are allowed. Claim(s) 1-12 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and is is are subject to restriction and is is are subject to by the Examination Papers The specification is objected to by the Examination and is are: Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct the oath or declaration is objected to by the	Irawn from consider down from consider the decision is required in the decision in the decisio	objected to by the Beld in abeyance. See If the drawing(s) is obj	e 37 CFR 1.85(a). ected to. See 37 CF	` '		
Priority ι	under 35 U.S.C. § 119						
a)	Acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority application from the International Bure See the attached detailed Office action for a life see the atta	ents have been re ents have been re riority documents eau (PCT Rule 1	eceived. eceived in Applications have been received 7.2(a)).	on No ed in this National	Stage		
2) 🔲 Notic 3) 🔯 Inform	e of References Cited (PTO-892) se of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/0 er No(s)/Mail Date ///24/03, 4/16/04, 10/25/04	08) 5) -; 8/22/03 6)	☐ Interview Summary Paper No(s)/Mail Da ☐ Notice of Informal P ☐ Other:	ite	·)-152)		

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1 2, 7 9 and 11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tanaka (Japanese Patent No. 2000178364) in view of Kitamura et al (U.S. Patent No. 5,834,098).

With regard to Claim 1, Tanaka discloses a label for in – mold forming (in – mold label; paragraph 0001, English translation) comprising a film comprising two layers comprising a surface layer and a heat sealing resin layer (a heat – adhesion resin laminated to a layer of a film '1,' which is a surface layer as shown in Figure 1, therefore a multilayer film; paragraph 0038, English translation); the surface layer comprises a thermoplastic resin composition (thermoplastic; paragraph 0032, English translation) and a filler (paragraph 0026, English translation) and has an average surface roughness of 0.2 µm, therefore a center line average surface roughness of 0.2 µm (paragraph 0029, English translation); Tanaka does not disclose the stretching of the film, and therefore discloses a non – stretched film. Tanaka fails to disclose a filler comprising an organic filler.

Kitamura et al teach the use of a filler comprising an organic filler (column 3, lines 3-6) in a label for in – mold forming (column 1, lines 15-16) for the purpose of obtaining a label having offset printability (column 2, line 27). One of ordinary skill in the art would therefore

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have recognized the advantage of providing for the filler of Kitamura et al in Tanaka, which comprises a label for in – mold forming, depending on the desired offset printability of the end product.

It therefore would have been obvious for one of ordinary skill in the art at the time

Applicant's invention was made to have provided for a filler comprising an organic filler in

Tanaka in order to obtain a label having offset printability as taught by Kitamura et al.

With regard to Claim 2, Tanaka discloses the claimed center line average surface roughness, and the label disclosed by Tanaka therefore has an ink adhesion strength of 1 kg cm or more.

With regard to Claims 7 - 8, the claimed aspect of the surface being roughened by pressing against a textured roll is directed to a process limitation, rather than a structural limitation, and is therefore given little patentable weight.

With regard to Claim 9, the heat – sealing resin layer disclosed by Tanaka undergoes emboss processing (in carrying out the laminating of the heat adhesion resin, it is desirable to give the coating approach that embossing is performed; paragraph 0043, English translation).

With regard to Claim 11, the label disclosed by Tanaka is made of three layers (a layered product more than a bilayer; paragraph 0030, English translation) comprising a propylene resin (propylene homopolymer; paragraph 0012, English translation) and therefore comprises a central layer comprising a propylene resin.

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3. Claim 3 is rejected under 35 U.S.C. 103(a) as being unpatentable over Tanaka (Japanese Patent No. 2000178364) in view of Kitamura et al (U.S. Patent No. 5,834,098) and Wolf (U.S. Patent No. 3,141,004).

Tanaka and Kitamura et al disclose a label comprising a multilayer resin film, therefore a polymer, for in – mold forming as discussed above. The film is transparent (paragraph 0029, English translation of Tanaka). Tanaka and Kitamura et al do not disclose that the film has an opacity of from 5 to 30 percent. However, Wolf discloses that a polymer (column 5, line 55) which is transparent has an opacity of below 50% (column 11, lines 9 – 11), which includes an opacity of 5%; Tanaka and Kitamura et al therefore disclose a film having an opacity of 5%.

4. Claims 4 – 6 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tanaka (Japanese Patent No. 2000178364) in view of Kitamura et al (U.S. Patent No. 5,834,098) and further in view of Ueda et al (U.S. Patent No. 5,652,326).

Tanaka and Kitamura et al disclose a film comprising two layers comprising a resin, and one layer also comprising an organic filler, as discussed above. The first layer comprises an polyolefinic resin (propylene – ethylene random copolymer; paragraph 0014, English translation of Tanaka) and the second layer comprises ethylene resin (ethylene – vinylacetate copolymer; paragraph; 0042, English translation). With regard to Claims 4 – 6, Tanaka and Kitamura et al fail to disclose a first layer comprising 94% by weight resin, 5% by weight of a permanent antistatic agent comprising polyether ester amide and 1% by weight of an organic filler and a second layer comprising 95% by weight ethylene resin and 5% by weight permanent antistatic agent comprising polyether ester amide.

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Ueda et al teach the use of an antistatic agent comprising polyether ester amide (column 1, lines 15 – 16), therefore a permanent antistatic agent, in a resin in the amount of 5% by weight (3 to 40% by weight; column 2, lines 24 – 26) and a resin in the amount of 94 – 95% by weight (60 – 97% by weight; column 2, lines 24 – 26) and a filler (column 12, lines 11 – 14) for the purpose of obtaining a resin having improved antistatic property (column 2, lines 39 – 41). One of ordinary skill in the art would therefore have recognized the advantage of providing for the antistatic agent of Ueda et al in Tanaka and Kitamura et al, which comprises a resin, depending on the desired antistatic property of the end product.

It therefore would have been obvious for one of ordinary skill in the art at the time Applicant's invention was made to have provided for a first layer comprising 94% by weight resin, 5% by weight of a permanent antistatic agent comprising polyether ester amide and 1% by weight of an organic filler and a second layer comprising 95% by weight ethylene resin and 5% by weight permanent antistatic agent comprising polyether ester amide in Tanaka and Kitamura et al in order to obtain a resin having improved antistatic property as taught by Ueda et al.

5. Claim 10 is rejected under 35 U.S.C. 103(a) as being unpatentable over Tanaka (Japanese Patent No. 2000178364) in view of Kitamura et al (U.S. Patent No. 5,834,098) and further in view of Asano (U.S. Patent No. 4,211,690).

Tanaka and Kitamura et al disclose a propylene resin as discussed above. Tanaka and Kitamura et al fail to disclose a propylene resin having moduli of tension of from 8000 to 40,000 kgf/cm² both lengthwise and crosswise.

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Asano et al teach a propylene resin (polypropylene resin; column 1, lines 55 – 57) having a modulus of tension (modulus in tension; column 1, lines 55 – 57) of from 8000 to 40,000 kg/cm² (12,000 kg/cm²; column 1, lines 55 – 57) for the purpose of obtaining a propylene resin having rigidity sufficient to prevent deformation (column 1, lines 66 – 8; column 2, lines 1 – 3). One of ordinary skill in the art would therefore have recognized the advantage of providing for the modulus of tension of Asano in Tanaka and Kitamura et al, which comprises propylene resin, depending on the desired rigidity of the end product.

It therefore would have been obvious for one of ordinary skill in the art at the time Applicant's invention was made to have provided for a propylene resin having a modulus of tension of from 8000 to 40,000 kgf/cm², therefore in all directions including lengthwise and crosswise, in Tanaka and Kitamura et al, in order to obtain rigidity sufficient to prevent deformation as taught by Asano et al.

6. Claim 12 is rejected under 35 U.S.C. 103(a) as being unpatentable over Tanaka (Japanese Patent No. 2000178364) in view of Kitamura et al (U.S. Patent No. 5,834,098) and further in view of Gergen et al (U.S. Patent No. 4,085,163).

Tanaka and Kitamura et al disclose an ethylene resin as discussed above. Tanaka and Kitamura et al fail to disclose an ethylene resin having a crystallinity of 10 to 60%, a number average molecular weight of from 10,000 to 40,000 and a melting point of from 50 to 130 degrees Celsius.

Gergen teaches an ethylene resin (low density polyethylene; column 8, line 49) having a crystallinity of 10 to 60% (over 35%; column 8, lines 50 - 51), a number average molecular weight of from 10,000 (above 10,000; column 8, lines 35 - 37) and a melting point of from 50 to

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130 degrees Celsius (100 degrees Celsius; column 8, lines 38 – 40) for the purpose of obtaining an ethylene resin having long term dimensional stability (column 1, lines 9 – 12). One of ordinary skill in the art would therefore have recognized the advantage of providing for the crystallinity, molecular weight and melting point of Gergen in Tanaka and Kitamura et al, which comprises an ethylene resin, depending on the desired dimensional stability of the end product.

It therefore would have been obvious for one of ordinary skill in the art at the time Applicant's invention was made to have provided for a crystallinity of 10 to 60%, a number average molecular weight of from 10,000 to 40,000 and a melting point of from 50 to 130 degrees Celsius in Tanaka and Kitamura et al in order to obtain an ethylene resin having long term dimensional stability as taught by Gergen.

7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Marc A Patterson whose telephone number is 571-272-1497. The examiner can normally be reached on Mon - Fri 8:30 AM - 5:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Harold Pyon can be reached on 571-272-1498. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Mare Petteron 9/19/05

Marc A. Patterson, PhD.

Examiner

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